



Attorney Docket No. 2000-096DIV7
PATENT

CERTIFICATE OF MAILING

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BY: Suzanne Shadley
Suzanne Shadley

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	Boussie et al.	Confirmation No.	4286
Serial No.:	10/720,380	Group Art Unit:	1751
Filed:	11/25/03		
For:	Substituted Pyridyl Amine Catalysts and Processes for Polymerizing Crystalline Polymers	Examiner:	Lu, Caixia

Santa Clara, California
June 8, 2005

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Sir:

Applicants request that the references cited herein be considered in connection with the examination of this application. The references are listed on the attached PTO-1449 form.

This is being filed after the first office action, and thus Applicants are paying the fee required by 37 CFR § 1.17(p) in the accompanying transmittal letter.

06/13/2005 RFEKADU1 00000008 500496 10720380
01 FC:1806 180.00 DA

Respectfully submitted,

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PTO-1449

2000-096DIV7

10/720,380

APPLICANT:
Boussie et al.

FILING DATE:
November 25, 2003

GROUP:
1751

CONFIRMATION NO.
4286

US PATENT DOCUMENTS

[illegible]

FOREIGN DOCUMENTS

[illegible]

OTHER DOCUMENTS *(including Author, Title, Date, Pertinent Pages Etc.)*

	Resconi et al., "Selectivity in Propene Polymerization with Metallocene Catalysts", <i>Chem. Rev.</i> 2000, 100, 1253-1345

DATE CONSIDERED:

Examiner: Initial if reference considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.